

SEMICONDUCTORS

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① Force = $qE = eE$
(for electron)

⑧ $E_g = \frac{E_c + E_v}{2}$
(for intrinsic) \leftarrow Fermi energy
 \leftarrow E of valence band
 \leftarrow E of conduction band

② $I = I_e + I_h$
 \downarrow electron \rightarrow holes

③ $n = p = n_i$ (for intrinsic semi)
 \uparrow e density \rightarrow intrinsic concentration
 \downarrow hole density

⑨ $n = 2 \left(\frac{2\pi m_e kT}{h^2} \right)^{3/2} e^{\frac{E_F - E_c}{2}}$
 \rightarrow number of e per V in the conduction band

⑩ $p = 2 \left(\frac{2\pi m_h kT}{h^2} \right)^{3/2} e^{\frac{E_v - E_F}{2}}$
 \rightarrow approx density of holes

④ $n \times p = n_i^2$ (for extrinsic semi)

⑪ $\sigma = A e^{-\frac{E_g}{2kT}}$

⑤ $I = neA v_d \leftarrow$ drift velo
 $= eA(nv_e + p v_h)$
 $\frac{V}{R} = eA(nv_e + p v_h)$

$\sigma = (\mu_e + \mu_h) 2e \left(\frac{2\pi kT}{h^2} \right)^{3/2} (m_e m_h)^{1/4} e^{-\frac{E_g}{2kT}}$

⑥ $\sigma = \frac{I}{V} = e(n\mu_e + p\mu_h)$
 \downarrow mobility

$\mu_e = \frac{v_e}{E}, \mu_h = \frac{v_h}{E}$

⑦ density of states $g(E)dE = \frac{g(E)dE}{V} = \frac{8\sqrt{2}\pi m^{3/2} \sqrt{E} dE}{h^3}$

(12) $D_n = \frac{\mu_n kT}{e}$, $D_p = \frac{\mu_p kT}{e}$ } Einstein relation
 Diffusion constant \rightarrow mobility

(13) $E_H = Bv$
 $= \frac{BJ}{ne}$

(14) $R_H = 1/ne \Rightarrow E_H = R_H BJ$

Hall Coeff. $R_H = -\frac{1}{ne}$ or $R_H = \frac{1}{pe}$

(15) $V_H = R_H BJ \pm$
 $= \frac{R_H BI}{b}$
 Hall voltage

(16) $F(E) = \frac{1}{e^{\frac{(E-E_F)}{kT}} + 1}$

Probability that an energy state is occupied.

DIFFERENTIATE

Intrinsic

- > No impurities
- > Electrical conductivity is Low
- > No classification
- > Rarely used in devices
- > $e = h$
- > Ex: Si & Ge

Extrinsic

- Added impurities
- High
- classified for ~~either~~ n type, p type
- Widely used
- $e > h$ in n type
 $h > e$ in p type
- Ex: As doped Si for n type, Al doped Si (or Ge) for p-type

N type

- > doping with Pentavalent impurities like As or antimony.
- > Electrons - majority carriers
- > Added impurities are called donor atoms, they donate one e^- per added ~~atom~~ atom.
- > Donor E level is just below CB
- > higher ~~the~~ electrical conductivity

P type

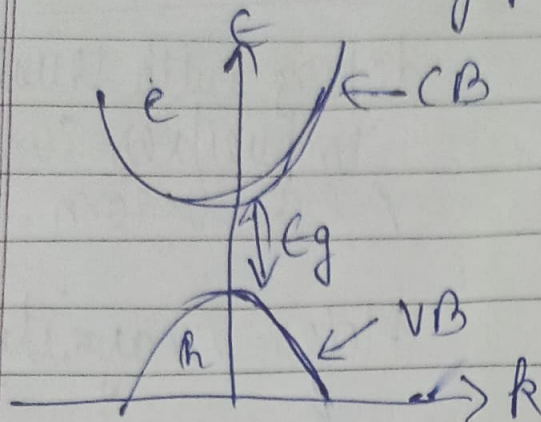
- doping with trivalent impurities such as Al or boron.
- Holes - majority carriers
- called acceptor atoms, accept one e^- atom
- Acceptor E level is ~~above~~ above VB
- lower

Imp p4Q

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Direct Band Gap



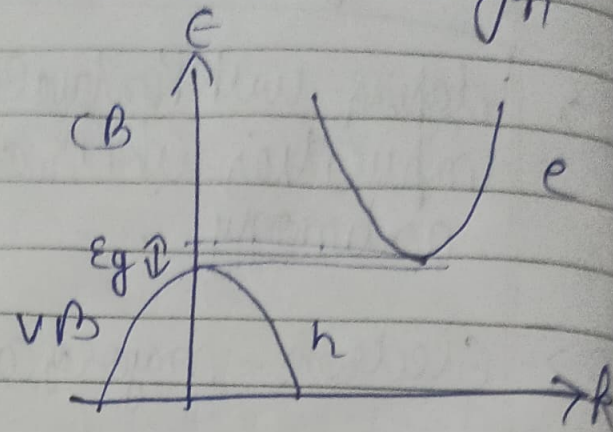
Max of VB & Min of CB occur at same momentum values

Electron making a transition from VB to CB need not undergo any change in its momentum

Compound GaAs are Direct BG semi.

These DBS are used in LEDs & semi. lasers

Indirect Band Gap



Max of VB & Min of CB occur at 2 diff momentum values.

Electron requires energy for the change in momentum in addition to the energy gap, E_g .

Comp Elemental Si, Ge, are indirect BG semi.

~~For~~ Note useful for LEDs & Semi. lasers.

Deriv

DERIVATIONS

CARRIER CONCENTRATION

$$dn = Z(E) F(E) dE$$

↑ number of ~~holes~~ electrons in $E \rightarrow E+dE$
in CB

$$n = \int_{E_c}^{\infty} Z(E) F(E) dE \quad - (1)$$

$$\cancel{Z(E)} Z(E) dE = \frac{g(E) dE}{V} = \frac{8\sqrt{2} J m^{3/2} \sqrt{E} dE}{h^3}$$

$$F(E) = \frac{1}{1 + e^{\frac{E - E_F}{kT}}} = \frac{1}{1 + e^{\frac{E - E_F}{kT}}}$$

$$E - E_F \gg kT \Rightarrow F(E) dE = \underline{e^{\frac{E_F - E}{kT}}}$$

$$(1) \text{ becomes } n = \int_{E_c}^{\infty} \frac{8\sqrt{2} J m_e^{*3/2} \sqrt{E - E_c} e^{\frac{E_F - E}{kT}} dE}{h^3}$$

$$= \frac{8\sqrt{2} J m_e^{*3/2}}{h^3} \int_{E_c}^{\infty} \sqrt{E - E_c} e^{\frac{E_F - E}{kT}} dE$$

$$\begin{aligned} E - E_c &= x \\ E &= E_c + x \\ dE &= dx \end{aligned} \Rightarrow C e^{\frac{E_F}{kT}} \int_{E_c}^{\infty} \sqrt{x} e^{-\frac{E_c + x}{kT}} dx$$

$$= \frac{8\sqrt{2} J m_e^{*3/2}}{h^3} e^{\frac{E_F - E_C}{KT}} \int_0^\infty \sqrt{x} e^{-\frac{x}{KT}} dx$$

$$n = \frac{8\sqrt{2} J m_e^{*3/2}}{h^3} e^{\frac{E_F - E_C}{KT}} (KT)^{3/2} \frac{\sqrt{J}}{x^2}$$

$$n = 2 \left(\frac{2 J m_e^{*} KT}{h^2} \right)^{3/2} e^{\frac{E_F - E_C}{KT}}$$

$$n = N_C e^{E_F - E_C / KT} \quad - (2)$$

~~electron concentration~~
electron concentration in CB

$$\text{Similarly } p = N_V e^{(E_V - E_F) / KT} \quad - (3)$$

$$N_V = 2 \left(\frac{2 J m_p^{*} KT}{h^2} \right)^{3/2}$$

$$n \cdot p = n_i^2$$

$$n \cdot p = N_C e^{E_F - E_C / KT} \cdot N_V e^{E_V - E_F / KT}$$

$$np = N_C N_V e^{E_V - E_C / KT} \quad - (4)$$

For intrinsic semiconductor,

$$n_i = p_i$$

$$n_i^2 = N_c N_v e^{-E_g/KT} \quad (5)$$

$$-E_g = -(E_c - E_v) \quad \leftarrow \text{we know that this}$$

$$\Rightarrow \text{from (4) \& (5), } np = n_i^2$$

FERMI LEVEL IN INTRINSIC

$$n_c = N_c e^{-(E_c - E_f)/KT} \quad (1)$$

$$n_v = N_v e^{-(E_f - E_v)/KT} \quad (2)$$

$$N_c = N_v \quad \& \quad n_c = n_v \quad \text{for intrinsic}$$

$$(1)/(2) \quad \& \quad E_c - E_f = E_f - E_v$$

$$\Rightarrow E_f = \frac{E_c + E_v}{2}$$

\Rightarrow lies in the middle of CB
Fermi level & VB

EINSTEIN EQN

At ∞ , with no applied E field, the free e distribution is uniform & there is no net current flow.

Any change in ∞ , which would lead to a diffusion current, creates an internal electric field and a drift current balancing the diffusion current component.

Thus:

$$D_n e E \mu_n = e D_n \frac{\partial \Delta n}{\partial x}$$

$$F = (\Delta n) e E = \frac{e D_n}{\mu_n} \frac{\partial \Delta n}{\partial x}$$

$F = KT \frac{\partial \Delta n}{\partial x}$ by corresponding to pressure gradient from kinetic theory of gases.

$$\Rightarrow KT = \frac{e D_n}{\mu_n}$$

$$\Rightarrow \boxed{D_n = \frac{\mu_n KT}{e}}$$

$$\Rightarrow \left(\frac{D_n}{\mu_n} = \frac{KT}{e} \right)$$